# Intrinsic non-flat-foldability of two-tile DDC surfaces composed of glide-reflected irregular quadrilaterals 

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#### Abstract

Functional origami tessellations have certain geometric or physical properties - such as flat-foldability and rigid-foldability - which make them of particular interest for a broad range of applications in science, engineering, and architecture. While some simple variations of certain functional origami tessellations can be designed trivially, a systematic symmetry-reduction scheme is proved to be productive for the computational generation of more complex, non-trivial variations. Such a scheme has been previously applied to the developable double corrugation (DDC) surface, widely known as the Miura-ori, resulting in the development of novel crystalline derivatives, the symmetry groups of which are subgroups of the parent pattern. Computational algorithms can search for and find flat-foldable solutions for a large number of derivatives of the DDC surface, but fail to find solutions for all of them. In this paper, we exploit the symmetry reduction scheme along with classical plane geometry to analytically demonstrate why some crystallographic derivatives of this pattern do not exist. To this end, by applying the local flat-foldability condition at the vertices of different orbits associated with each tessellation, we show that such patterns are never flat-foldable, regardless of the geometric specifications of their constituting quadrilateral facets. In particular, we prove that two-tile DDC surfaces composed of glide-reflected irregular quadrilaterals are intrinsically non-flat-foldable, resulted from geometric incompatibilities between the properties of certain unit cells and the local flat-foldability condition.


## 1. Introduction

Origami - the traditional art of paper folding - has inspired countless practical applications over the past few decades. In particular, some origami tessellations have attracted the enormous interest of science and engineering communities, as a result of their design versatility and favourable mechanical properties such as limited degrees of freedom [1-4], stiffness-tunability [5-10], flat-foldability [11,12], and rigid-foldability [13-16] (stiffness-tunability is the condition of having tunable structural stiffness; flat-foldability means that an originally planar thin sheet can be folded to a second 'flat' configuration; rigidfoldability implies that the facets of the origami structure remain flat during folding/unfolding).

One of the most noted and widely-used origami tessellations in science, engineering, and architecture is the developable double corrugation (DDC) surface, popularly known as the Miura-ori. As can be seen from Fig. 1a, the crease lines of this pattern form parallelograms (more precisely, a single parallelogram repeated in two directions) which tessellate the plane. Variations of the DDC surface have also found numerous applications. As a result, developing new functional variations could potentially expand the range of applications for such a fold pattern in various fields. To this end, the next section presents the mathematical concepts and definitions that are necessary to explore and design new variations for this tessellation.

## 2. Theoretical background

From a mathematical standpoint, symmetry is an intrinsic property of every repetitive structure. On a broader level, symmetry analysis is an insightful approach to the design and analysis of engineering structures of different types such as truss structures [17-28], tensegrities [29-32], and layered space grids $[33,34]$. Therefore, to analyse the composition and design of a given tessellation, one needs to investigate symmetry elements associated with that tessellation.

Transformational geometry is the branch of mathematics studying geometric transformations, which underlie the modern understanding of symmetry [35]. A transformation $\tau$ on a set $S$ is a function from $S$ to $S$ that is both one-to-one and onto, i.e. it is a one-to-one correspondence from $S$ to itself $[36,37]$. An isometry is a distance-preserving transformation. Mathematically speaking, a transformation $\tau: \mathbb{R}^{2} \rightarrow \mathbb{R}^{2}$ is an isometry of the plane $\mathbb{R}^{2}$ if for any two points $P$ and $Q$ of $\mathbb{R}^{2}$, the Euclidean distance between $P$ and $Q$ remains invariant, i.e., $|\tau(P)-\tau(Q)|=|P-Q|$ $[38,39]$. In fact, an isometry is a special case of a similarity (similarities are angle-preserving transformations which characterise Euclidean geometry) [40,41].

With the above concepts and definitions in mind, one can observe that every infinite, two-dimensional tessellation is composed of a design motif transformed by a group of isometries to cover the plane without any gap or overlap. In general, the isometries of the two-dimensional

[^0](a)

(b)

(c)


Fig. 1. (a) Folding sequence of a typical developable double corrugation (DDC) surface or the Miura-ori; a $2 \times 2$ unit of this pattern is illustrated along with the mountain-valley assignment of crease lines (the thickness of the surface is assumed to be negligible). (b) Different types of non-trivial isometries of the plane. (c) Two standard choices for the smallest pmg unit cell for the Miura fold pattern (top), and the symmetry reduction of a pmg unit cell to a pg unit cell by removing the centres of rotation and axes of reflection (bottom right). The blue shaded area shows the fundamental region of the pattern. Different colours for a symmetry element represent different classes of that element in the pattern. The directions in which horizontal lines and zigzag polylines travel are respectively called the longitudinal and transverse directions of the pattern, represented by the $y$ - and $x$-axes, respectively. The unit fragment of the pattern, composed of two adjacent parallelograms (denoted by $P$ ), is illustrated on the top right.


Fig. 2. (a) The core quadrilateral (depicted by red dashed lines) and the distribution of the total flat-foldability error for a typical octagonal unit fragment associated with the two plane symmetry groups $p 1$ and $p 2$. (b) Close-up of error distribution showing two local minima. (c) Two flat-foldable solutions corresponding to the two minima given in part b.
plane include the identity, rotations, reflections, and glide reflections, as illustrated in Fig. 1b.

According to the classification of two-dimensional symmetry groups [42,43], the symmetry of the Miura fold pattern is $22^{*}$ in the Orbifold notation [44], $\left[(\infty, 2)^{+}, \infty\right]$ or $\left[\infty,(2, \infty)^{+}\right]$in the Coxeter notation (see, e.g., [45] or [46]), or $p m g$ in the International Union of Crystallography (IUCr) notation [47]. In this paper, the Miura fold pattern is denoted by M. According to [48], there are two choices for the smallest unit cell of a given Miura crease pattern that both match the standard pmg unit cell used in the IUCr tables [47], as illustrated in Fig. 1c: the 'primary standard' choice $S$, and the 'alternative standard' choice $S^{+}$. It has been shown [48] that these two initial choices produce the same descendants
for some symmetric variations, whereas they generate different results for some others. Hereafter in this study, those descendants of the Miuraori which can only be generated based on $\mathrm{S}^{+}$are denoted by $\mathrm{M}^{+}$.

A 'unit fragment' of a tessellating mesh is defined as a minimal collection of adjacent facets which can generate the entire tessellation using its respective translation vectors [49]. As illustrated on the top right of Fig. 1c, the unit fragment of a Miura fold pattern is composed of two adjacent parallelograms (denoted by $P$ ) which share a fold line on the horizontal lines of the pattern.

Designers and researchers in various fields have proposed a range of variations for the Miura-ori [11,50-52]. A framework for the generalisation of this origami tessellation is developed and presented in [49].


Fig. 3. (a) An $\mathrm{M}\left(p g_{2,2}\right)$ tessellation. (b) An $\mathrm{M}^{+}\left(p g_{2,2}\right)$ tessellation. Different colours for glide reflection axes (dashed lines) represent different classes of the symmetry element in the patterns (i.e., $G_{\mathcal{L}, 1}$ and $G_{\mathcal{L}, 2}$ ). The orientation of each quadrilateral is reserved because glide reflection is an indirect (or sense-reversing) isometry, as can be seen from the $2 \times 2$ module of representative squares on the bottom right corner of each tessellation.


Fig. 4. An $\mathrm{M}\left(\mathrm{pg}_{2,2}\right)$ tessellation. (a) State 0 : a given Miura fold pattern. (b) State 1: a symmetrically perturbed state using all degrees of freedom.


Fig. 5. A pair of consecutive quadrilaterals in the $y$-direction from State 1 of the previous figure.

According to this framework, a repetitive convex quadrilateral mesh designed by displacing the nodes of a conventional DDC crease pattern is called $G_{i, j}$, where $G$ is the name of its maximal plane symmetry group, and $i$ and $j$ are the number of quadrilaterals in the $x$ - and $y$-directions, respectively, within the unit cell of the pattern. The $y$-direction is the direction of the parallel fold lines in the Miura fold pattern before applying variations. Variations of the DDC crease pattern which can only be designed based on the alternative standard unit cell $\mathrm{S}^{+}$(shown in Fig. 1c) are denoted by $G^{+}{ }_{i, j}$. This framework was applied to the design of a range of isomorphic [53] and non-isomorphic [54] symmetric descendants of the Miura-ori. It should be noted that according to this framework the mountain-valley assignment of the crease lines does not affect the symmetry of a tessellation.

While some simple flat-foldable variations of the DDC crease pattern can be designed trivially, some others require careful crystallographic considerations and geometric calculations. A systematic symmetryreduction scheme is proved to be productive for the generation of some more complex, non-trivial derivatives. The design of some of these nontrivial variations involves considerable geometric complexities which require effective computational strategies and algorithms.

To explore the existence and design of such diverse solutions, here we present a computational framework which evaluates the flatfoldability of various degree-4 tessellations. Consider a central point $M=\left[\begin{array}{ll}X_{0} & Y_{0}\end{array}\right]$ and four surrounding points $N_{1}=\left[\begin{array}{ll}X_{1} & Y_{1}\end{array}\right], N_{2}=\left[\begin{array}{ll}X_{2} & Y_{2}\end{array}\right]$, $N_{3}=\left[\begin{array}{ll}X_{3} & Y_{3}\end{array}\right]$, and $N_{4}=\left[\begin{array}{ll}X_{4} & Y_{4}\end{array}\right]$ in the Cartesian coordinate system. Let us define a $4 \times 2$ matrix $\mathbf{N}=\left[\begin{array}{llllll}N_{1} & N_{2} & N_{3} & N_{4}\end{array}\right]^{T}$ containing all the surrounding points. The line segment connecting each point $N_{i}(i=1$, $2, \ldots, 5$; and $N_{5} \equiv N_{1}$ ) to node $M$ is denoted by $l_{i}$ and the angle between any two successive line segments $l_{i}$ and $l_{i+1}$ in the counter-clockwise direction around $M$ is named $\alpha_{i(i+1)}$ (note that $\alpha_{45}=\alpha_{41}$ as $N_{5} \equiv N_{1}$ ). We define the local flat-foldability error function, $\varepsilon$, as a function of $\mathbf{N}$ and $M$ as follows
$\varepsilon(\mathbf{N}, \boldsymbol{M})=\left(\pi-\left\{\alpha_{12}(\mathbf{N}, \boldsymbol{M})+\alpha_{34}(\mathbf{N}, \boldsymbol{M})\right\}\right)^{2}$

To show examples for trivial and non-trivial solutions, let us consider the boundaries of a general $2 \times 2$ module (i.e., an 'octagonal unit fragment' [12]) as illustrated in Fig. 2a. Denoting the errors for nodes $N_{4}, N_{5}, N_{6}$ and $M$ (the unknown central vertex) as $\varepsilon_{4}, \varepsilon_{5}, \varepsilon_{6}$, and $\varepsilon_{m}$, respectively, the total flat-foldability error $\varepsilon_{t}$ of the tessellation is defined as
$\varepsilon_{t}=\sqrt{\varepsilon_{4}^{2}+\varepsilon_{5}^{2}+\varepsilon_{6}^{2}+\varepsilon_{m}^{2}}$


Fig. 6. An example of a $\mathrm{pgg}^{+}{ }_{2,2}$ variation of the Miura-ori, consisting of two different starting parallelograms $P_{1}$ and $P_{2}$. Solid and dashed lines represent mountain and valley folds, respectively. The blue shaded area shows the fundamental region of the pattern. Different colours for a symmetry element represent different classes of that element in the pattern [54].


Fig. 7. Design generation process of the $p g_{2,2}$ derivative of the DDC surface.


Fig. 8. An $\mathrm{M}^{+}\left(p g_{2,2}\right)$ tessellation. (a) State 0 : a given Miura fold pattern. (b) State 1: a symmetrically perturbed state using all degrees of freedom.

We use this definition for the total flat-foldability error as an objective function to be minimized. Fig. 2a shows the 'core quadrilateral' [12] and the distribution of the total flat-foldability error for a typical octagonal unit fragment associated with the two plane symmetry groups with parallelogram unit cells, i.e. $p 1$ and $p 2$. A close-up of the error distribution in the vicinity of the two local minima of the error function is shown in Fig. 2b. As can be seen from Fig. 2c, one of these two minima generates a trivial solution, $M_{\mathrm{T}}$, for which the internal fold lines are piece-wise parallel to the borders of the octagonal unit fragment; this produces an $\mathrm{M}^{+}\left((p 2)_{2,2}\right)$ derivative of the DDC surface, which is globally-planar. On the other hand, the other local minimum generates a non-trivial solution, $M_{\mathrm{NT}}$, which produces an $\mathrm{M}\left((p 1)_{2,2}\right)$ derivative of the DDC surface, which is globally-curved.

In contrast to the above example, there are some cases in which whilst the geometry is relatively simple and the number of unknowns is only a few, we can observe that no computational algorithm would generate any valid flat-foldable solution. The non-existence of such functional variations is generally a result of clashes between crystallographic restrictions and the local flat-foldability condition. The next section deals with two specific derivatives of the Miura-ori which are of this type.

## 3. Design and analysis of $p g$ derivatives of the DDC surface

In transformational geometry, a reflection in line $\mathcal{L}$, denoted by $R_{\mathcal{L}}$, followed by a translation $T$ parallel to $\mathcal{L}$, denoted by $T_{\mathcal{L}}$ (alternatively, the translation followed by the reflection), is called a glide reflection, represented by $G_{\mathcal{L} \mid T}$ in this paper. In other words
$G_{\mathcal{L} \mid T}(P)=\left[R_{\mathcal{L}} \circ T_{\mathcal{L}}\right](P)=\left[T_{\mathcal{L}} \circ R_{\mathcal{L}}\right](P)$,
where $P$ is a point on the plane and $\bigcirc$ denotes the composition of functions. In the $x-y$ Cartesian coordinate system, with the assumptions that $\mathcal{L}$ passes through $O$ and makes an angle $\varphi$ with the positive $x$-axis (i.e., $\mathcal{L}: y=x \tan \varphi$ ), the transformed coordinates of point $P$ under $G_{\mathcal{L} \mid T}$, denoted by $P^{\prime}$, can be expressed as
$P^{\prime}=\left[\begin{array}{l}x^{\prime} \\ y^{\prime}\end{array}\right]=G_{\mathcal{L} \mid T}(P)=\left[\begin{array}{cc}\cos 2 \varphi & \sin 2 \varphi \\ \sin 2 \varphi & -\cos 2 \varphi\end{array}\right]\left[\begin{array}{l}x \\ y\end{array}\right]+\left[\begin{array}{l}T_{x} \\ T_{y}\end{array}\right]$.
Amongst the seventeen plane symmetry groups, the group pg is the only group that contains glide reflections only, without any rotations or reflections. Depending on the choice of the standard unit cell (see Fig. 1c), there are two minimal $p g$ derivatives of the DDC crease pattern in the longitudinal direction. These two $p g$ derivatives, represented by $\mathrm{M}\left(p g_{2,2}\right)$ and $\mathrm{M}^{+}\left(p g_{2,2}\right)$, are depicted in parts a and b of Fig. 3, respectively. As can be seen from the figure, both patterns are composed of two irregular quadrilaterals, with a difference in their compositions, as conceptualised by a $2 \times 2$ module of representative squares on the bottom right corner


Fig. 9. A pair of consecutive quadrilaterals in the $y$-direction from State 1 of the previous figure.


Fig. 10. Two line segments $A M$ and $A N$, parallel to $B_{g} A_{l}$ and $B_{g} A_{g}$ respectively, are added to the previous figure to form triangles $T_{1}$ and $T_{2}$.
of each tessellation. This section proves the impossibility of flat-folding such tessellations.

### 3.1. The $\mathrm{M}\left(\mathrm{pg}_{2,2}\right)$ tessellation

Theorem 3.1. An $\mathrm{M}\left(p g_{2,2}\right)$ tessellation is never flat-foldable.
Proof. An $\mathrm{M}\left(p g_{2,2}\right)$ unit cell is depicted in its original configuration, State 0, in Fig. 4a. There are two distinct orbits of nodes associated with the unit cell, shown as $A_{0}$ and $B_{0}$. Since we are dealing with a $p g$ group, we have a degree of freedom for the aspect ratio of the unit cell ( $r_{x}$ is the scale factor in the $x$-direction). We are allowed to move nodes $A_{0}$ and $B_{0}$ in the $x$ - or $y$-directions; however, we know that $p g$ cannot fix the unit cell in the $x$-direction. Therefore, for a fixed set of $\bar{a}, y_{A}, y_{B}$, there is a single degree of freedom for $x_{A}-x_{B}$. (It should be noted that changing the sign of $x_{A}-x_{B}$, while keeping the other degrees of freedom fixed, makes the pattern reflected with respect to the $x$-axis). In Fig. 4b, we have perturbed the pattern using all the degrees of freedom that we introduced earlier to obtain a new configuration, State 1.

With the purpose of examining the application of the flat-foldability condition to the pattern at nodes $A$ and $B$, we have illustrated a pair of consecutive quadrilaterals in the $y$-direction, from State (2) of the previous figure, in Fig. 5. Nodes with index $r$ represent the equivalent nodes on the right of respective nodes. For clarity, as we are dealing with a geometry problem, we ignore the naming scheme for symmetrically equivalent nodes associated with a unit cell. We have renamed the grey nodes $A$ and $B$ (see Fig. 5) as $A_{g}$ and $B_{g}$, where $g$ stands for glide-reflected.

Line segments $A B$ and $B_{g} A_{g}, r$ have the same length, and the same acute angle (the absolute value of the angle is considered) with respect to the $y$-axis, $\mu$, as a result of the glide-reflection transformation. There is a similar relationship between line segments $B A_{r}$ and $B_{g} A_{g}$, which


Fig. 11. $Q_{1}$ and $Q_{2}$ are two congruent isosceles trapezoids, $T$, with a base equal to $\frac{a}{2}+\left|x_{A}-x_{B}\right|$ and a height (altitude) equal to $b$.
intersect the $y$-axis at an angle axis $v$ (we assume that $\mu \neq 0$ and $\nu \neq 0$ ). Applying the local flat-foldability condition at node $B_{g}$, we obtain
$\alpha+\beta=\pi$,
which implies that
$A B \| A_{g} B_{g}$.
In other words
$\mu=\nu$.
Therefore, $T_{1}=A A_{r} B$ and $T_{2}=A_{g} A_{g, r} B_{g}$ are two congruent isosceles triangles. As a result
$A B=A_{g} B_{g}$.
From Eqs. (6) and (8) we conclude that $Q_{2}$ must be a parallelogram. Similarly, it can also be concluded that $Q_{1}$ must be a parallelogram. Hence, the pattern is a $\mathrm{pg}^{+}{ }_{2,2}$ variation of the Miura-ori presented in Fig. 6. For $\mu=v=0$, the pattern is a Miura-ori.

From the above discussion, we conclude that a flat-foldable $p g_{2,2}$ derivative of the Miura-ori does not exist. The design generation process leading to this conclusion is illustrated in Fig. 7.

### 3.2. The $M^{+}\left(\operatorname{pg}_{2,2}\right)$ tessellation

In the previous section, we proved that a flat-foldable $p g_{2,2}$ variation of the Miura-ori, $\mathrm{M}\left(p g_{2,2}\right)$, does not exist. Starting from the alternative standard unit cell, $\mathrm{S}^{+}$, illustrated in Fig. 1, this section discusses the $p g^{+}{ }_{2,2}$ variation of the Miura-ori, $\mathrm{M}^{+}\left(p g_{2,2}\right)$.

## Theorem 3.2. An $\mathrm{M}^{+}\left(p g_{2,2}\right)$ tessellation is never flat-foldable.

Proof. An $\mathrm{M}^{+}\left(p g_{2,2}\right)$ unit cell is depicted in its original configuration, State 0 , in Fig. 8a. Similar to the $\mathrm{M}^{+}\left(p g_{2,2}\right)$ case, there are two distinct orbits of nodes associated with the unit cell, shown as $A_{0}$ and $B_{0}$. The details of the degrees of freedom for this case are similar to the $p g_{2,2}$ variation discussed earlier. As can be seen in Fig. 8b, we have perturbed the pattern using all the degrees of freedom that we introduced earlier to obtain a new configuration, State 1.

To investigate the application of the flat-foldability condition to the pattern at nodes $A$ and $B$, we have illustrated a pair of consecutive quadrilaterals in the $y$-direction, from State 1 of the previous figure, in Fig. 9. For clarity, as we are dealing with a geometry problem, we ignore the naming scheme for symmetrically equivalent nodes associated with a unit cell. We have renamed the black nodes $A_{1}$ and $B_{1}$ as $A$ and $B$, respectively, and the grey nodes $A_{1}$ and $B_{1}$ as $A_{g}$ and $B_{g}$, respectively where $g$ stands for glide-reflected. Nodes with index $l$ represent the equivalent nodes on the left of each node $A$ or $B$.

Line segments $B_{l} A$ and $A_{l} B_{g}$ have the same length, and the same acute angle (the absolute value of the angle is considered) with respect to the


Fig. 12. A tessellation based on the previous figure; it is a non-legitimate variation of the Miura-ori with a (maximal) symmetry group cmm.


Fig. 13. The pair of consecutive quadrilaterals of Fig. 9 when $\mu=\nu=0$.
$y$-axis, $\mu$, as a result of the glide-reflection transformation. There is a similar relationship between line segments $A B$ and $B_{g} A_{g}$, which intersect the $y$-axis at an angle $v$. We assume that $\mu \neq 0$ and $v \neq 0$.

The two hatched triangles $B_{l} A B$ and $A_{l} A_{g} B_{g}$ are congruent, as they have two congruent corresponding angles with a congruent included side. Therefore, the following relationship exists between their corresponding angles at nodes $A$ and $B_{g}$

$$
\begin{equation*}
\zeta+\gamma=\varepsilon+\delta \tag{9}
\end{equation*}
$$

Applying the local flat-foldability condition, we can write the following equations in terms of the fold angles around nodes $A$ and $B$
$\alpha+\zeta=\pi$,
$\beta+\varepsilon=\pi$.
Substituting the equivalents for $\zeta$ and $\varepsilon$ from Eqs. (10) and (11) into Eq. (9) gives
$\alpha+\delta=\beta+\gamma$.
On the other hand, the internal angles of quadrilateral $Q_{2}$ must add up to $2 \pi$, i.e.
$\alpha+\beta+\gamma+\delta=2 \pi$.

From Eqs. (12) and (13) we can conclude
$\alpha+\delta=\beta+\gamma=\pi$.
This implies that $A B_{g}$ is parallel to $B A_{g}$ (and so to $B_{l} A_{l}$ ). In other words
$\sigma=\tau$.
The previous figure is repeated in Fig. 10 with some additional elements. A line is drawn from node $A$ parallel to $B_{g} A_{l}$ to intersect $B_{l} A_{l}$ at a point $M$. The quadrilateral $M A_{l} B_{g} A$ is a parallelogram, as it has two pairs of parallel opposite sides. Consequently, $A M$ has the same length as $B_{g} A_{l}$, and as we already know that $B_{g} A_{l}=B_{l} A$, we conclude that triangle $T_{1}=B_{l} M A$ is isosceles. As a result, we have
$\varepsilon=\zeta$.
In a similar way, and by drawing line segment $A N$ parallel to $B_{g} A_{g}$ from node $A$, we can conclude that
$\delta=\gamma$.
On the other hand, in parallelogram $B_{l} A_{l} A_{g} B$, the two adjacent angles at nodes $B_{l}$ and $A_{l}$ must add up to $\pi$, i.e., $(\varepsilon+\mu)+(\zeta+\mu)=\pi$; this gives
$\varepsilon+\mu=\frac{\pi}{2}$.
In a similar way, we can conclude
$v+\delta=\frac{\pi}{2}$.
Hence
$\tau=0$.
Referring to Eq. (15), we conclude
$\sigma=\tau=0$.
This means that parallelogram $B_{l} A_{l} A_{g} B$ must be a rectangle. It also implies that nodes $A$ and $B_{g}$ must be mirror nodes. Therefore, the following relationships must be satisfied
$\zeta=\gamma$ and $\varepsilon=\delta$.
We know from elementary geometry that if in a triangle an altitude is also a bisector, the triangle is isosceles. Therefore
$A B=A B_{l}=\frac{a}{2}+\left|x_{A}-x_{B}\right| \quad$ and $\quad \mu=v=\arctan \left(\left|x_{A}-x_{B}\right| / b\right)$.
As a result, $Q_{1}$ and $Q_{2}$ are two congruent isosceles trapezoids, $T$, with a base equal to $\frac{a}{2}+\left|x_{A}-x_{B}\right|$ and a height (altitude) equal to $b$, as shown in Fig. 11.


Fig. 14. Design generation process of the $\mathrm{pg}^{+}{ }_{2,2}$ derivative of the DDC surface.

A tessellation based on the previous figure is depicted in Fig. 12. It is a non-legitimate [49] variation of the Miura-ori, and its (maximal) symmetry group is cmm . In fact, it is a $90^{\circ}$ rotated version of the bellow (or accordion) pattern (see, e.g. [51]).

Now we consider the case when $\mu=v=0$. In this case, in order to have a flat-foldable pattern, both nodes $A$ and $B$ must be mirror nodes. Furthermore, as $B_{l} B$ and $A_{l} A_{g}$ are parallel, nodes $A$ and $B_{g}$ (and consequently $B$ ) must be geometrically congruent. As a result, there is only one acute angle in the pattern. In other words
$\alpha=\gamma=\varepsilon=\eta$.
Also we have
$\tau=\sigma=\frac{\pi}{2}-\alpha$.
Therefore, $Q_{1}$ and $Q_{2}$ are two different parallelograms, $P_{1}$ and $P_{2}$, sharing a side, as shown in Fig. 13. However, a tessellation based on $P_{1}$ and $P_{2}$ is not strictly $p g$, but it is $p m g^{+}{ }_{2,2}$. If $P_{1}$ and $P_{2}$ are congruent, the resulted tessellation is the original Miura-ori. From the above discussion, we conclude that a flat-foldable $\mathrm{pg}^{+}{ }_{2,2}$ variation of the Miura-ori does not exist.

From the above discussion, we conclude that a flat-foldable $\mathrm{pg}^{+}{ }_{2,2}$ variation of the Miura-ori does not exist. The design generation process leading to this conclusion is illustrated in Fig. 14.

## 4. Conclusions

Exploring crystalline design variations of the developable double corrugation (DDC) surface or the Miura-ori, in this paper we studied the two minimal pg variations of this crease pattern in the longitudinal direction, namely $\mathrm{M}\left(p g_{2,2}\right)$ and $\mathrm{M}^{+}\left(p g_{2,2}\right)$. Both of these two tessellations are composed of two irregular quadrilaterals which tile the plane by glide reflections and translations, without having any rotational or reflectional symmetries. The main geometric difference between these two tessellations is that $\mathrm{M}\left(p g_{2,2}\right)$ has a composition similar to a checkerboard, while $\mathrm{M}^{+}\left(\mathrm{pg}_{2,2}\right)$ consists of alternate strips of glide-reflected images of one tile.

By applying the local flat-foldability condition at the vertices of different orbits associated with each tessellation, we proved that such patterns are never flat-foldable, regardless of the geometric specifications of the two irregular quadrilaterals. This is because of the incompatibility between the crystalline structure of the patterns and the condition of local flat-foldability. In other words, we showed that no two irregular quadrilateral tiles can constitute a flat-foldable, developable double corrugation surface.

## Declaration of Competing Interest

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence the work reported in this paper.

## CRediT authorship contribution statement

Pooya Sareh: Conceptualization, Methodology, Formal analysis, Visualization, Writing - original draft. Yao Chen: Investigation.

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